

Supplementary material for “Semiconductor-Metal Structural Phase Transformation in MoTe₂ Monolayers by Electronic Excitation”

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Outline

1. Simulation methods
2. Dynamical stability of MoTe₂ monolayer under biaxial strain
3. Density of states of MoTe₂ H monolayer

Simulation methods

Optimization of crystal structures and calculation of ground state energies were done using density functional theory (DFT) with the projector augmented wave (PAW) [1] method implemented in the Vienna Ab initio Simulation Package (VASP) [2,3]. Activation energy barriers, defined as the energy difference between the H crystal structure and the configuration at the saddle point along the semiconducting-to-metal phase transition pathway, were calculated using the climbing image nudged elastic band method (CI-NEB) method implemented in the VASP Transition State Tools code [4].

Exchange and correlation effects are calculated using the Perdew–Burke–Ernzerhof form of the generalized gradient approximation to the exchange–correlation functional [5]. Valence electron wave functions are constructed using a plane wave basis set containing components up to a kinetic energy of 450 eV and the reciprocal space is sampled at the Γ point with a Gaussian smearing of orbital occupancies of 0.1 eV. All DFT calculations are conducted on a $6 \times 6 \times 1$ supercell of the MoTe₂ monolayer containing a total of 36 formula units (108 atoms) of MoTe₂. Monolayers are separated from their periodic images (in the out-of-plane direction) by a large vacuum of 20 Å to remove spurious image interactions. Calculations were performed till each self-consistency cycle is converged in energy to within 1×10^{-8} eV/atom and forces on ions are under 5×10^{-4} eV/Å.

Density of electronic states was plotted using DFT calculations on previously optimized $6 \times 6 \times 1$ MoTe₂ monolayer supercells where the reciprocal space was sampled using a dense Γ -centered $9 \times 9 \times 1$ k-point mesh and partial occupancies of eigenlevels are determined by the tetrahedron method [6]. Fermi surfaces of the H crystal in the ground and excited state are constructed from DFT calculations on a $1 \times 1 \times 1$ unitcell of the MoTe₂ monolayer performed at high-accuracy using a plane-wave cutoff of 650 eV and a Γ -centered $15 \times 15 \times 1$ k-point mesh.

Dynamical stability was inferred from the frequency of normal vibration modes of the H crystal structure. The Hessian matrix was generated within the formalism of density functional perturbation theory and dispersion relations for normal vibration modes were calculated using the open-source phonopy package [7]. For both NEB and phonon dispersion calculations, excited states are described within the Δ -SCF DFT framework. In this scheme, a non-Aufbau constraint is imposed on orbital occupancies to promote electrons from the occupied Kohn-Sham energy levels to unoccupied higher-energy levels followed by relaxation of nuclear positions to minima in the potential energy surface defined by the charge density corresponding to the fixed occupancy of these energy levels. The Δ SCF method is an inexpensive approximation to the potential energy surface of the excited state system with accuracy comparable to time-dependent density functional theory methods [8,9]. The Δ SCF method is widely used to describe spatially localized excited-state wavefunctions in isolated molecules, but can also characterize excitations in organic systems and semiconductor clusters and nanodots, where excited states are delocalized over several hundred atoms [10,11]. Δ SCF schemes have also been used to describe excited electronic states of adsorbates and crystal surfaces, where ground-state and excited wavefunctions are delocalized over the entire periodic supercell [12].

Dynamic stability under biaxial lattice strain

While elastic strain engineering can affect the relative stability of the H and T' polytypes, this change in the potential energy landscape was found to not significantly affect the dynamical stability of the ground state crystal. This is confirmed by a calculation of phonon dispersion relations of unstrained and strained H MoTe₂ films, which do not show any appreciable softening of vibration modes along important points along the hexagonal Brillouin zone. This high dynamical stability of the H polytype under strain implies the lack of low-energy atomic distortions that are necessary for the existence of a low-energy phase transition pathway.

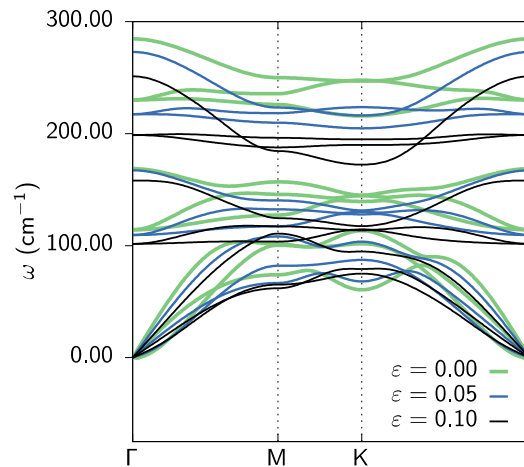


FIG. S1: A plot of the phonon band structure of monolayer MoTe₂ at three representative tensile lattice strains of $\varepsilon = 0.00, 0.05, 0.10$ shows no noticeable softening along high-symmetry paths in the first Brillouin zone.

Density of states of MoTe₂ H monolayer

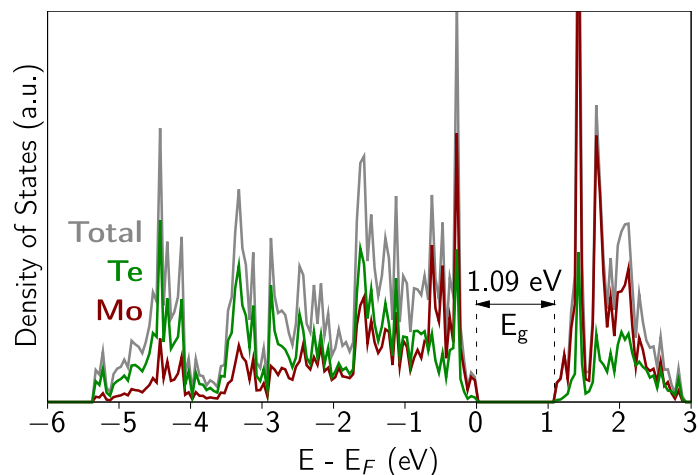


FIG. S2: Calculated density of electronic states in the MoTe₂ monolayer (gray). Red and blue lines show the density of states projected on to spheres of radius 2.15 Å centered on Mo and Te atoms respectively.

The calculated band gap of the MoTe₂ monolayer in our simulations is 1.09 eV, which is consistent with experimental values measured by optical means. The valence and conduction band edges are dominated by Mo d-states, which is consistent with observations from other monolayer TMC crystals.

Electronic structure of electron-doped MoTe₂ H monolayer

Figure S3 shows the phonon dispersion curve of electron-doped MoTe₂ H monolayer at three representative charge carrier concentrations of 0, 0.5 and 1.0 × 10¹⁴ cm⁻². n-type MoTe₂ monolayers show imaginary vibration frequencies at electron concentrations above 10¹⁴ cm⁻², identical to the case of electronically excited TMDCs. This similarity arises due to similarities in the Fermi surface and associated nesting vectors of the electronically-excited and electron-doped MoTe₂ monolayer.

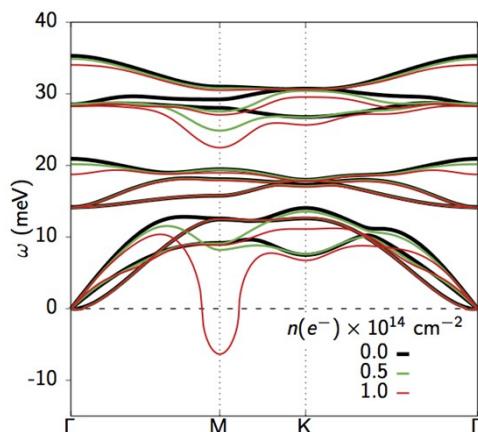


Figure S3: Phonon dispersion curve of electron-doped MoTe₂ monolayers at three different electron concentrations of $n = 0, 0.5, 1.0 \times 10^{14} \text{ cm}^{-2}$ shows phonon softening at the M-point at high charge carrier concentrations, identical to electronically-excited monolayers.

To identify if photogenerated holes play a significant role in the strong electron-phonon coupling and phonon softening observed in electronically excited MoTe₂ monolayers, we plot the isosurface of hole states in the first Brillouin zone in Figure S4. These hole states are localized around the K-point in reciprocal space and do not show $\Gamma\bar{M}$ nesting vectors that could lead to softening of *M*-point phonons. This indicates that the observed phonon softening in electronically-excited and electron-doped MoTe₂ crystals results primarily from electron occupation of high-energy eigenlevels.

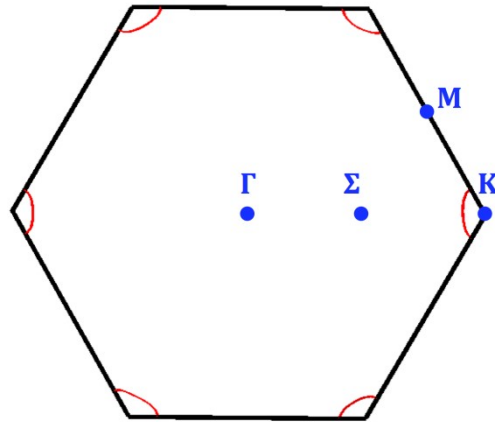


Figure S4: Isosurfaces of hole-states (red curves) in excited MoTe₂ monolayers are localized at the *K*-point and do not show nesting vectors along the $\Gamma\bar{M}$ direction, which are responsible for phonon softening at the *M*-point.

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